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Microstructural characterization and isothermal oxidation behavior of hot-pressed TiB₂–10 wt.% TiSi₂ composite

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This paper reports on the results of fine-scale microstructural characterization and isothermal oxidation of hot-pressed TiB_2 —10 wt.% $TiSi_2$ composite. The careful analysis of selected-area diffraction patterns using transmission electron microscopy confirms the presence of Ti_5Si_3 as a reaction product along with TiB_2 and $TiSi_2$ phases. The results of oxidation testing at 1200 °C for 12 h using a thermogravimetric analyzer illustrate near-parabolic oxidation scale growth characteristics. The oxidation mechanisms are discussed with reference to thermodynamically feasible oxidation reactions. © 2009 Acta Materialia Inc. Published by Elsevier Ltd. All rights reserved.

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In the last two decades, structural ceramics, in particular, have received wider attention owing to the growing need for high-performance materials in aerospace, automotive sectors and recently for high-temperature applications [1–7]. Among various high-temperature ceramics, titanium diboride (TiB₂) is one of the important materials, belonging to the class of transition metal borides. TiB₂ is characterized by a very good combination of properties, including a relatively high melting point (3225 °C), hardness, high-specific strength, excellent electrical and thermal properties, and good corrosion and wear resistance [8,9].

In fact, for high-temperature structural applications, TiB₂ reinforced with the non-metallic sinter additives is preferred in view of its better properties. Nevertheless, it is very important to understand whether such additives are desirable as far as the high-temperature oxidation properties of TiB₂ are concerned. In general, the oxidation behavior of non-oxide ceramics like TiB₂ largely depends on the composition and properties of the oxidation products [10]. Modification of the chemical composition of the oxide layer is one of the important methods of controlling the oxidation of the ceramics. Recently, numerous studies have reported an improvement in the oxidation resistance of transition metal bor-

ides reinforced with 10–30 vol.% of ceramic additives (such as SiC, Si₃N₄, MoSi₂, etc.), which are Si sources [10–16]. The oxidation resistance of these ceramics can be improved as a result of the formation of a protective borosilicate glass surface layer.

In an earlier study, investigation revealed that TiB_2 could be densified to >99% of theoretical density (ρ_{th}) with the use of $TiSi_2$ up to 10 wt.% [17]. In continuation of research efforts to realize high-temperature applications of the ceramics developed, an attempt has been made to study the finer-scale microstructure and oxidation resistance of TiB_2 reinforced with $TiSi_2$. The isothermal oxidation of the TiB_2 composite, performed at 1200 °C for 12 h using a thermogravimetric analyzer (TGA) is also reported.

In order to prepare TiB₂–10 wt.% TiSi₂ composition, appropriate amounts of commercial TiB₂ (Grade F, H.C. Starck GmbH and Co., Goslar, Germany) and TiSi₂ (Goodfellow Cambridge Limited, UK) powders were mixed by wet ball-milling for 12 h in a polyethylene bottle, using SiC balls and ethanol as media. The hotpressing experiments were carried out at a temperature of 1650 °C for 1 h, with an applied pressure of 30 MPa and a heating rate of 15 °C min⁻¹ in a flowing argon gas atmosphere. More details on the starting powders, hot pressing and density measurement are reported elsewhere [17].

The crystalline phases in the starting powders and hot-pressed sample were analyzed by X-ray diffraction

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(XRD) using Cu K_{α} radiation. The microstructural investigation of the phase assemblages of the samples was performed by transmission electron microscopy (TEM). TEM observations were performed using a 200 kV Technai G² T-20 UTWIN TEM (FEI, Eindhoven, Netherlands), equipped with a high-angle annular dark field (HAADF) detector.

For oxidation experiments, $3 \times 4 \times 10$ mm ceramic coupons were cut using electrodischarge machining (EDM) from the hot-pressed discs. After belt grinding, the samples were polished with diamond paste up to $0.25 \,\mu m$ finish and finally polished with γ -Al₂O₃ (0.05 µm). Prior to the oxidation tests, the polished samples were ultrasonically cleaned in acetone for 10 min and dried at 80 °C overnight. The oxidation tests were carried out at 1200 °C for 12 h in a dry air atmosphere with a heating rate of 30 °C min⁻¹, followed by free cooling. At least two samples from each composition were used. The weight gains were continuously recorded with 10^{-3} mg accuracy, using a TGA (mod. STA409, NETZSCH Gertebau GmbH, Germany) equipped with a vertically heated Al₂O₃ chamber. The samples were placed on platinum supports to separate them from the Al₂O₃ holder. The surface and subsurface of the oxidized samples were analyzed using XRD and scanning electron microscopy (SEM; Quanta model and SIRION model) attached with energy-dispersive spectroscopy (EDS; Oxford Instruments ultrathin window EDS facility) and X-ray mapping to assess the oxide products and to observe the surface morphology of the oxide scales.

The TiB_2 –10 wt.% $TiSi_2$ could be densified to >99% ρ_{th} after hot pressing the samples at 1650 °C for 1 h. XRD analysis of the starting powder composition reveals the presence of TiB2 and TiSi2 phases, while the hot-pressed sample consists of an additional Ti₅Si₃ secondary phase along with the TiB₂ and TiSi₂ (Fig. 1a and b). The presence of a new phase (Ti₅Si₃) suggests the involvement of sintering reactions during the hot pressing of TiB₂-TiSi₂ material. The details of thermodynamically favorable sintering reactions and sintering mechanisms are beyond the scope of the present paper and are reported elsewhere [17]. In Figure 1c, a HAADF TEM image shows the existence of three contrasting phases in the TiB₂-10 wt.% TiSi₂. The phases are marked on the figure. The morphology of TiB₂ grains is either spherical or platelet, and the average grain size of TiB₂ varies between 2 and 3 μm. The size of the Ti₅Si₃ grains ranges from 100 to 150 nm. The microstructure of the sample typically represents bimodal grain morphology with a small fraction of coarser elongated TiB2 grains along with finer TiB2 grains, which corroborates the liquid phase sintering (LPS) microstructure. A bright field conventional TEM image of the sample consisting of various microstructural phases is shown in Figure 1d. The Ti₅Si₃ phase is observed to be located at the triple pocket and surrounded by the TiB₂ and TiSi₂ grains. The selected-area diffraction patterns (SADP) from various grains confirm the TiB2 with HCP structure, TiSi2 with orthorhombic structure, and Ti₅Si₃ with HCP structure. The morphology and size of Ti₅Si₃ grains at the triple points of the TiB₂ and TiSi₂ is a clear signature of LPS. An important feature of the sintered microstructure is the dislocation activity in some of the TiB₂ grains. Figure 2 is a bright field image showing a TiB₂ grain with dislocation activity. The presence of dislocations was also reported for the TiB₂–TiC system [18]. Ting and Lu attributed the enhanced densification of MgA-l₂O₄ spinel to the dislocation substructure [19,20]. The dislocations can act as a short-circuit diffusion path for mass transport during sintering. Hence it is believed that the dislocation activity within the TiB₂ grains in addition to the LPS enhances the sinterability of TiB₂.

Figure 3a shows the variation in weight gain ΔW per unit surface area S as a function of temperature T. In order to compare the oxidation behavior of the TiB₂-TiSi₂ composite with the monolithic TiB2, the weight gain data of monolithic TiB₂ (densified to 96% ρ_{th} after hot pressing at 1800 °C for 1 h) are also presented in Figure 3a and b. The details of hot pressing, microstructure and oxidation behavior of monolithic TiB₂ are reported elsewhere [21]. It can be noted here that the weight gain of the TiB₂-10 wt.% TiSi₂ composite is relatively lower than that of the monolithic TiB₂. In general, for both the TiB₂ samples the weight gain shows an increasing trend with temperature. At ~500 °C, the oxidation of the sample is started, and a very slow mass gain is noticed up to 750 °C. Such slow oxidation kinetics is mainly due to the formation of molten B_2O_3 , which acts as a protective layer and inhibits the diffusion of oxygen. However, the increase in temperature to 1000 °C causes a sharp increase in the oxidation of the sample, and this is attributed to a rapid increase in the evaporation rate of B₂O₃. It has been widely reported that oxidation starts at \sim 400–500 °C for the monolithic TiB₂, and the oxidation process is governed mainly by a diffusion mechanism up to 900 °C [22-24]. The oxidation of TiB₂ depends on either the inward diffusion of oxygen ions or the outward diffusion of metal ions into the surface. At high temperatures, borosilicate glass forms, and it hinders the oxygen diffusion and slows down the oxidation kinetics of TiB₂-10 wt.% TiSi₂. Hence the diffu-

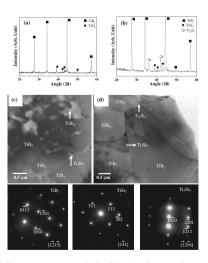


Figure 1. XRD patterns recorded with (a) the starting powder TiB₂–10 wt.% TiSi₂ composition and (b) the hot-pressed TiB₂–10 wt.% TiSi₂ composite. (c) HAADF TEM image reveals various contrasting phases in the hot-pressed sample. (d) Conventional TEM BF image showing the grain morphology of the various constituent phases. The corresponding SADP were taken from TiB₂, TiSi₂ and Ti₅Si₃ phases.

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